



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Ko et al.

Serial No.: 09/711,324

Filed: November 13, 2000

For: ETCHANT WITH SELECTIVITY
FOR DOPED SILICON DIOXIDE OVER
UNDOPED SILICON DIOXIDE AND
SILICON NITRIDE, PROCESSES WHICH
EMPLOY THE ETCHANT, AND
STRUCTURES FORMED THEREBY

Confirmation No.: 7008

Examiner: K. Chen

Group Art Unit: 1765

Attorney Docket No.: 2269-3526.4US
(97-1136.05/US)

CERTIFICATE OF MAILING

I hereby certify that this correspondence along with any attachments referred to or identified as being attached or enclosed is being deposited with the United States Postal Service as First Class Mail on the date of deposit shown below with sufficient postage and in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

12/29/03
Date

Signature

Brick G. Power
Name (Type/Print)

AMENDMENT

Mail Stop Non-Fee Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Sir:

This Amendment is being filed in response to the Office Action mailed on September 22, 2003, the three-month shortened statutory period for response to which expired on December 22, 2003. This Amendment is being filed with a petition for a one-month extension of time and the appropriate fee.

Amendments to the claims are set forth in the listing of the claims, which begins on page 2 of this paper; and

Remarks start at page 8 of this paper..

01/08/2004 AWONDAF1 00000056 09711324

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